						T			
FORM PTO-1449/A and B (Modified)  INFORMATION DISCLOSURE  STATEMENT BY APPLICANT					APPLICATION NO.: 09/676,251 CONFIRMATION NO.: 3371				
					ATTY. DOCKET NO.: T00428/70090 TJO/RHW				
					FILING DATE: September 29, 2000 APPLIC		CANT: Vadala et al.		
Sheet Sheet 1				G	GROUP ART UNIT: 1771 EXAM:		INER: Hai Vo		
	NW 1	52000		U.S.	PATENT DOCUMENTS			<del>.</del>	
Examiner's Initials#	o Cite	Y/		Kind	Name of Patentee or Applicant of Cited Document		Date of Publication or of issue of Cited Document MM-DD-YYYY		
h/	1	5,456,976		Code	LaMarca, II et al.	10/10/1995			
		<del>                                     </del>		<u> </u>					
			·						
				<u> </u>					
•	<u> </u>					•			
	<del></del>	T		FOREI	GN PATENT DOCUMENTS			t-	
Examiner's Initials#	Cite No.	Foreign Patent Docum Office/ Country Number		Ment Kind Code	Name of Patentee or Applicant of Cited Document (not necessary)		Date of Publication of Cited Document MM-DD-YYYY	Translation (Y/N)	
					· · ·				
	REO								
				1			ENJED 8 2002		
·						$AP_{R_{\underline{1}}}$	8 200		
			<del></del>		7		2002		
	<u> </u>		***	L	8	~ <del>77</del>	ÛU		
	T	Include r			N PATENT LITERATURE DOCUMENT TAIL LETTERS) title of the article (wh	412			
Examiner's Initials#	Cite No.	Include name of the author (in CAPITAL LETTERS) title of the article (when appropriate item (book, magazine, journal, serial, symposium, catalog, etc.), date, relevant page(smumber(s), publisher, city and/or country where published.						Translation (Y/N)	
W	Intl. Search Report for PCT/US01/42396								
			W-100-1						
-									
ĘXAMINER	<b>t</b>		tails		DATE CONSIDERED	06/	14/02		
include copy of the	his form v	ith next comm	unication to applica	nt.	onformance with MPEP 609; Draw line throug				
relied upon for ar	rerence is rearlier fil	ing date under	35 U.S.C. 120 (cont	tinuation, con	omitted to the office in a prior application, Seria tinuation-in-part, and divisional applications).	u 19U	, nied	, aid	

[NOTE - Must provide a copy of any patent, publication, other information listed, even if it was previously submitted to, or cited by, the U.S. Patent Office in an earlier application, unless the earlier application is identified by the IDS and is relied upon for an earlier filing date under 35 U.S.C. §120, and the copy was provided in the earlier application.]